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Docket No.: 050099-0355

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of	:	Customer Number: 20277
Fukashi MORISHITA, et al.	:	Confirmation Number: Not Yet Assigned
Application No.: Not Yet Assigned	:	Group Art Unit: Not Yet Assigned
Filed: September 18, 2006	:	Examiner: Not Yet Assigned
For: SEMICONDUCTOR MEMORY DEVICE	:	

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In accordance with the provisions of 37 C.F.R. 1.56, 1.97 and 1.98, the attention of the Patent and Trademark Office is hereby directed to the references listed on the attached form PTO-1449. It is respectfully requested that the references be expressly considered during the prosecution of this application, and that the references be made of record therein and appear among the "References Cited" on any patent to issue therefrom.

This Information Disclosure Statement is being filed with the application and no certification or fee is required.

A copy of the foreign search report is attached for the Examiner's information. Please note this is a PCT application in the entry of the National Phase in the U.S. and copies of the references cited were transmitted by WIPO and are believed to be in the file of the above identified application and readily available to the Examiner. Therefore it is believed that Applicants have met all requirements regarding duty of disclosure under 37

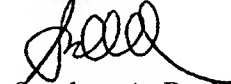
ALL REFERENCES CONSIDERED EXCEPT WHERE LINED THROUGH. /P.L./

CFR 1.56. Acknowledgement and consideration of these documents are respectfully requested.

Since the Search Report was from the JPO search authorities, copies of these references should have been supplied to the USPTO under the trilateral agreement and are believed to be in the file of the above identified application and readily available to the Examiner. However, to ensure that these references are available to the Examiner, we are providing copies of these references herewith.

Respectfully submitted,

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**Please recognize our Customer No. 20277
as our correspondence address.**

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SHEET 1 OF 1

INFORMATION DISCLOSURE CITATION IN AN APPLICATION				ATTY. DOCKET NO. 050099-0355		SERIAL NO. Not Yet Assigned 10/593275	
(PTO-1449)				APPLICANT Fukashi MORISHITA, et al.			
				FILING DATE September 18, 2006		GROUP Not Yet Assigned	
U.S. PATENT DOCUMENTS							
EXAMINER'S INITIALS	CITE NO.	Document Number Number-Kind Code ² (if known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document		Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	
		US 2002-0114191 A1	08/22/2002	Iwata et al.		Corresponds to JP 2003-86712	
		US 6,204,534	03/20/2001	Adan		Corresponds to JP 10-209456	
		US					
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FOREIGN PATENT DOCUMENTS							
EXAMINER'S INITIALS	CITE NO.	Foreign Patent Document Country Codes-Number 4-Kind Codes (if known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document		Pages, Columns, Lines Where Relevant Figures Appear	Translation Yes No
		JP 2003-86712	03/20/2003	TOSHIBA CORP		Corresponds to US 2002-0114191 A1	X
		JP 10-209456	08/07/1998	SHARP CORP		Corresponds to US 6,204,534	X
		JP 2002-260381	09/13/2002	TOSHIBA CORP			X
OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)							
EXAMINER'S INITIALS	CITE NO.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.					
		Kuo, C., et al. "A Capacitorless Double Gate DRAM Technology for Sub-100-nm Embedded and Stand-Alone Memory Applications" IEEE Transactions of Electron Devices, December 2003, Vol. 50, No. 12, pp. 2408-2416.					
		Kuo, C., et al. "A Capacitorless Double Gate Cell" IEEE Electron Device Letters, June 2002, Vol. 23, No. 6, pp. 345-347.					
		Ohsawa, T., et al. "Memory Design Using One-Transistor Gain Cell on SOI" Digest of Technical Papers, IEEE International Solid-State Circuits Conference, February 5, 2002, pp. 152-153, 454-455.					
EXAMINER /Peter Loxas/				DATE CONSIDERED 07/15/2009			

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

1 Applicant's unique citation designation number (optional). 2 Applicant is to place a check mark here if English language Translation is attached.

ALL REFERENCES CONSIDERED EXCEPT WHERE LINED THROUGH. /P.L./